

Growth and Characterization of Magnetic 6.1 Å Materials

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Collaborators

University at Buffalo

- X. Chen, M. Cheon and S. Wang: *growth*
- K.P. Mooney, F. Gasparini: *magnetism*
- T. Yeo, F. Lehmann, M.H. Na, B.D. McCombe: *transport/magneto-transport*
- G. Kioseoglou, Y.L. Soo, S. Kim, Y.H. Kao: *x-ray*
- M. Furis, G. Itskos, G. Kioseoglou, A. Petrou: *optics and magneto optics*
- G. Comanescu: *IR spectroscopy*

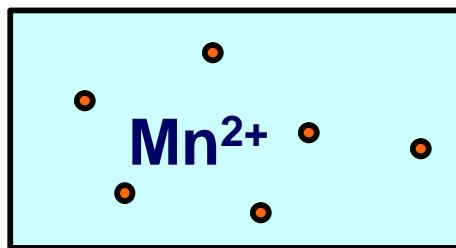
Notre Dame: Y. Sasaki, X. Liu, J.K. Furdyna: *growth*

Penn. State University: P. Schiffer: *SQUID*

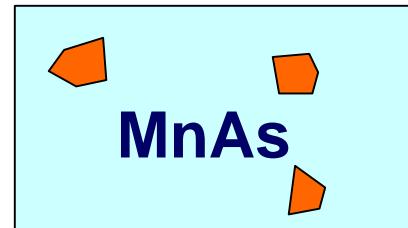
NRL: J. Meyer: *theory*

$\text{III}_{1-x}\text{Mn}_x\text{V}$ Materials (InMnAs and GaMnAs)

- Started by H. Munekata and H. Ohno (late 80s)
- $\text{III}_{1-x}\text{Mn}_x\text{V}$'s without precipitates (grown below 300°C for GaMnAs)
- All $\text{III}_{1-x}\text{Mn}_x\text{V}$'s are heavily p-type
- Mn is a dopant (acceptor) in III-V's; not desirable for alloying



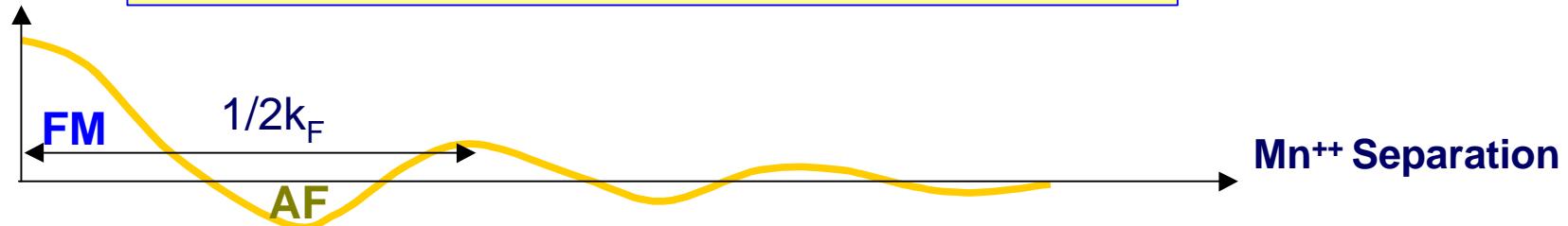
$T_{\text{growth}} < 300^\circ\text{C}$ (GaMnAs)



$T_{\text{growth}} > 300^\circ\text{C}$ (GaMnAs)

MAGNETIC INTERACTION

RKKY (Carrier Mediated Exchange)



Free carrier – Mn⁺⁺ interaction can be either ferromagnetic or antiferromagnetic

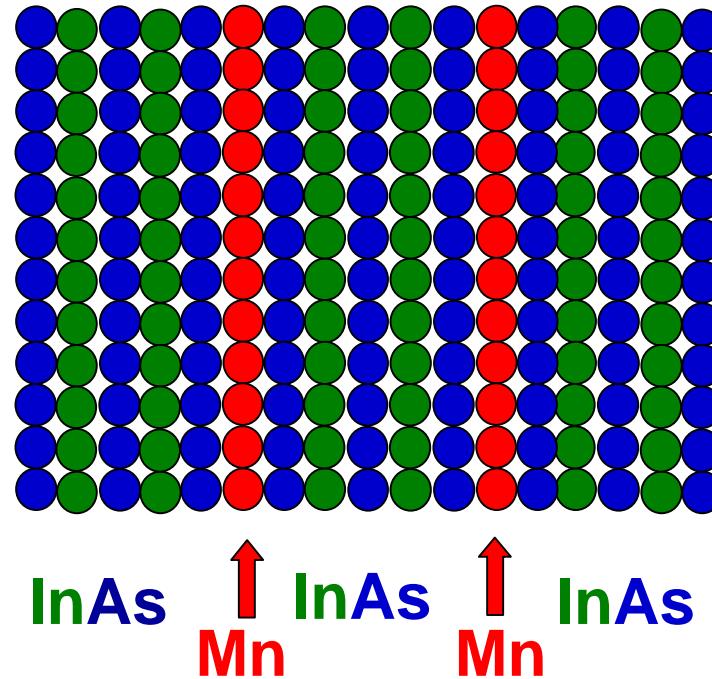
Important parameters

- Mn-Mn spacing and carrier density

Things to consider

- electronic, transport, optical and *magnetic* properties

APPROACH



- Controlled Mn spacing in the growth direction
- δ -Doping

Magnetic 6.1 Å Materials

“Multifunction” + Spin (Light) Polarization

- IR detectors and light emitter
- Resonant tunneling diodes (**RITDs**)
- High Electron Mobility Transistors (**HEMT’s**)

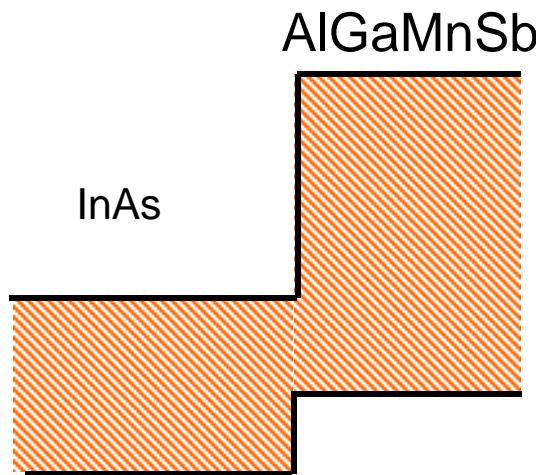
6.1 Å Materials + Mn → New Opportunities

- Natural advantages
- Charge separation and induced magnetism

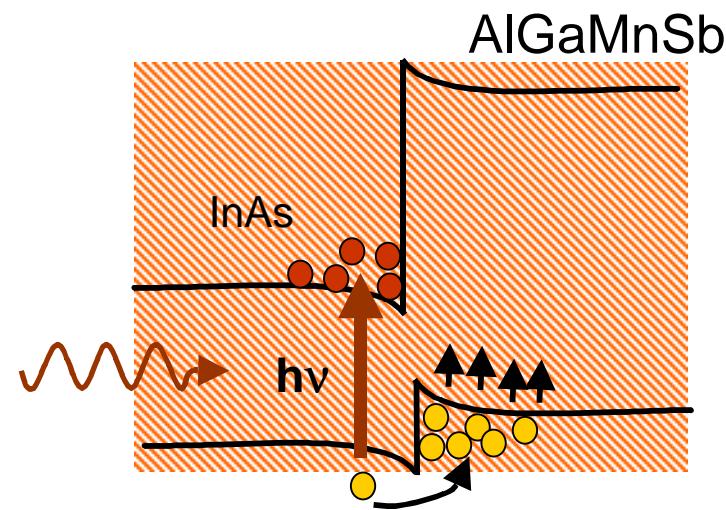
Photo(carrier)-induced Ferromagnetism

- Type-II Band Alignment → electron-hole separation
→ control of hole concentration by either light or an applied electric field
- Mechanism for ferromagnetism is carrier-induced

Photo-induced ferromagnetism



No Illumination

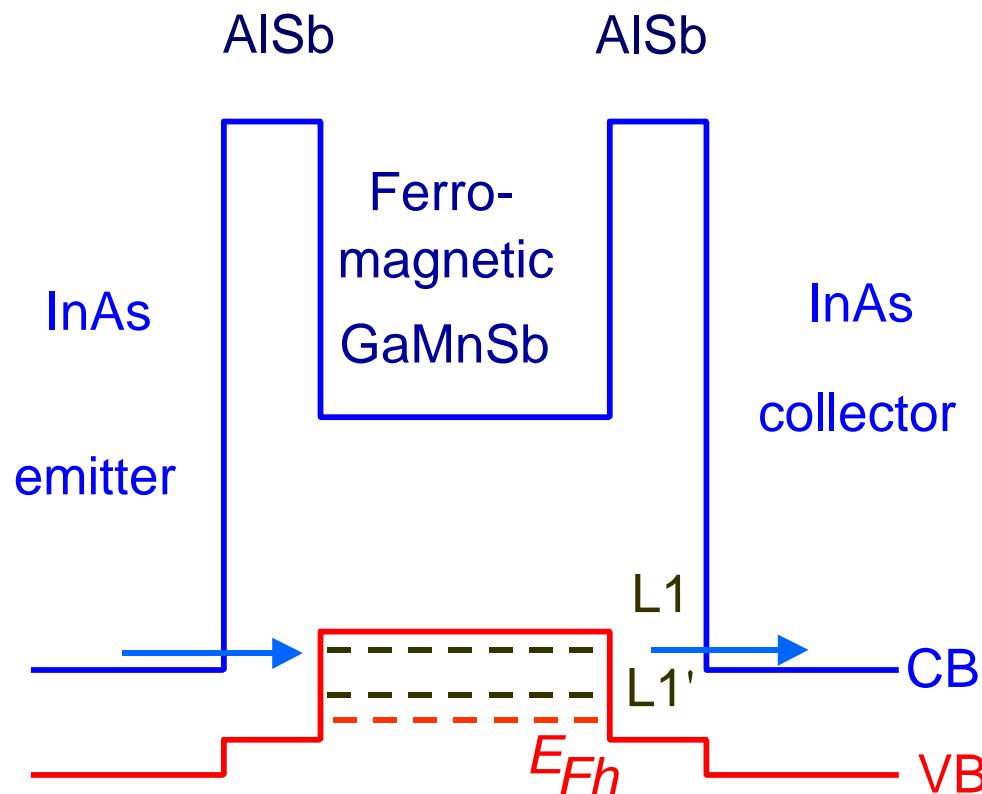


$$E_g (\text{InAs}) < h\nu < E_g (\text{AlGaMnSb})$$

Munekata *et al*, PRL 78, 4617 (1997) (InMnAs)

A DEVICE EXAMPLE

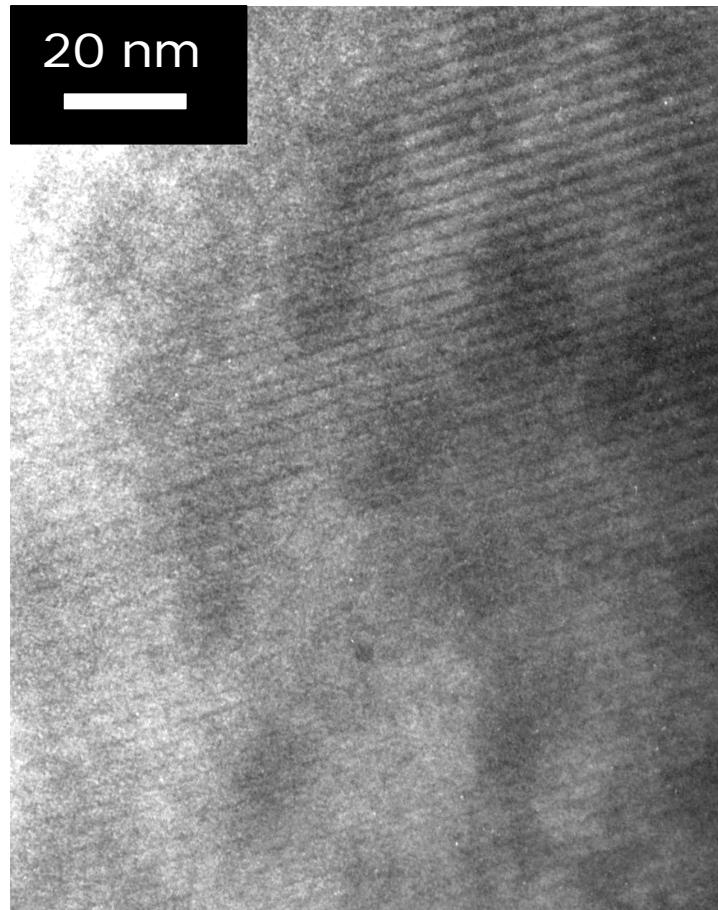
Ferromagnetic resonant interband tunnelling diode (FRITD)



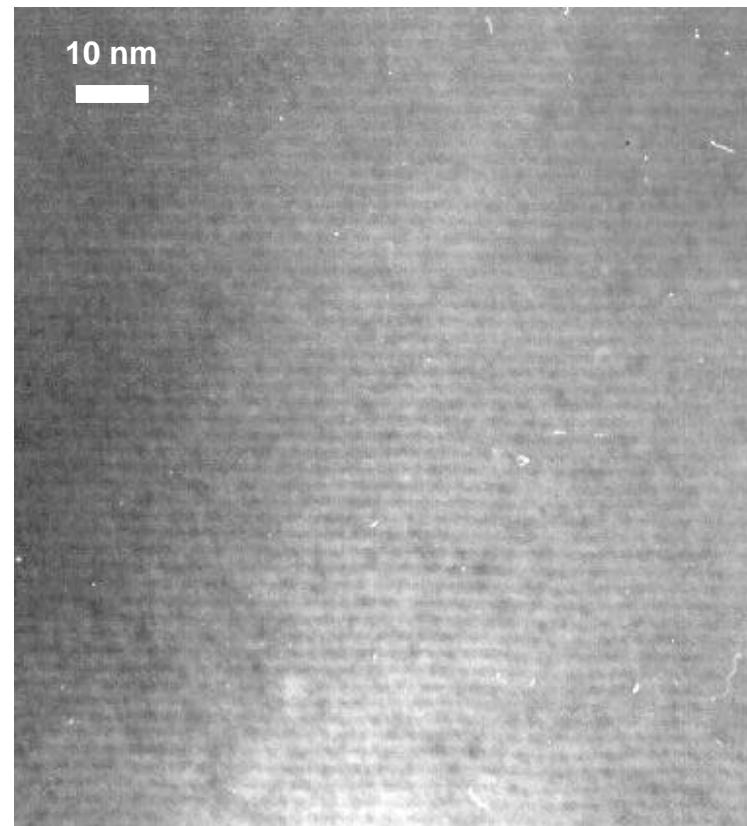
- Spin splitting of the light hole level allows spin polarized tunneling
- Mostly electron transport
- Electrically tunable

J. Meyer and L.R. Ram-Mohan

TEM of III-V/Mn Digital Alloys

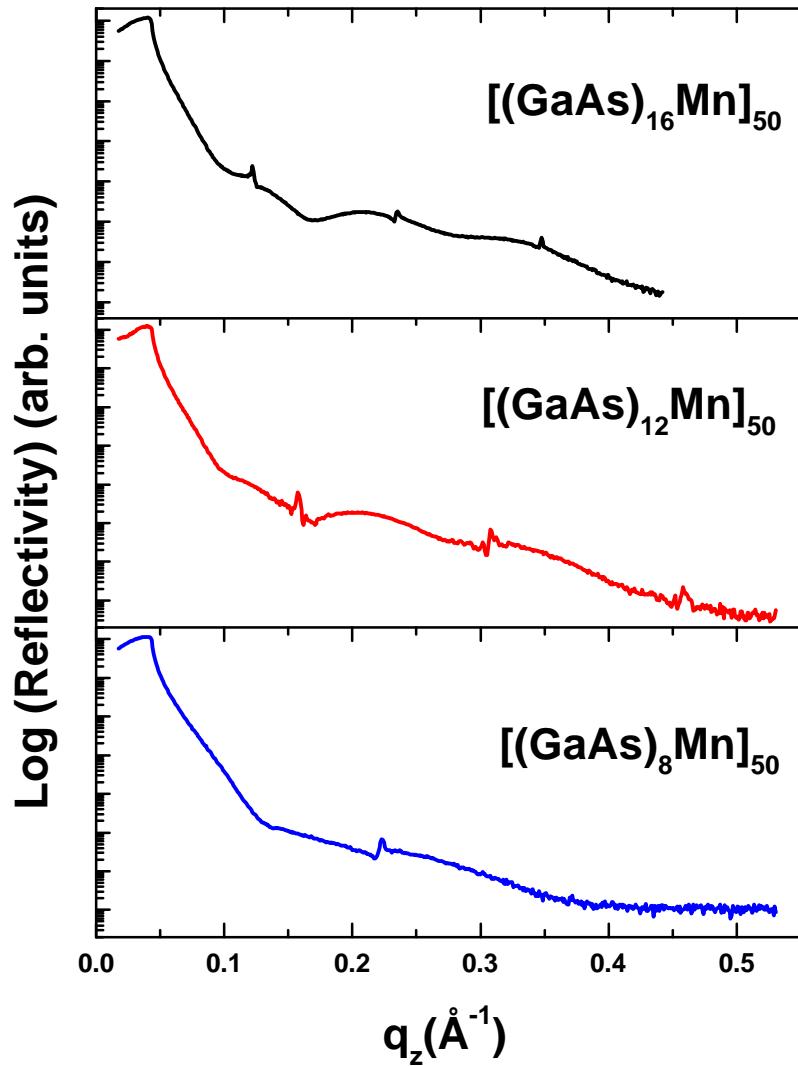


GaSb (10 ML)/Mn (.5 ML)



GaAs (7 ML)/Mn (.5 ML)

X-RAY REFLECTIVITY



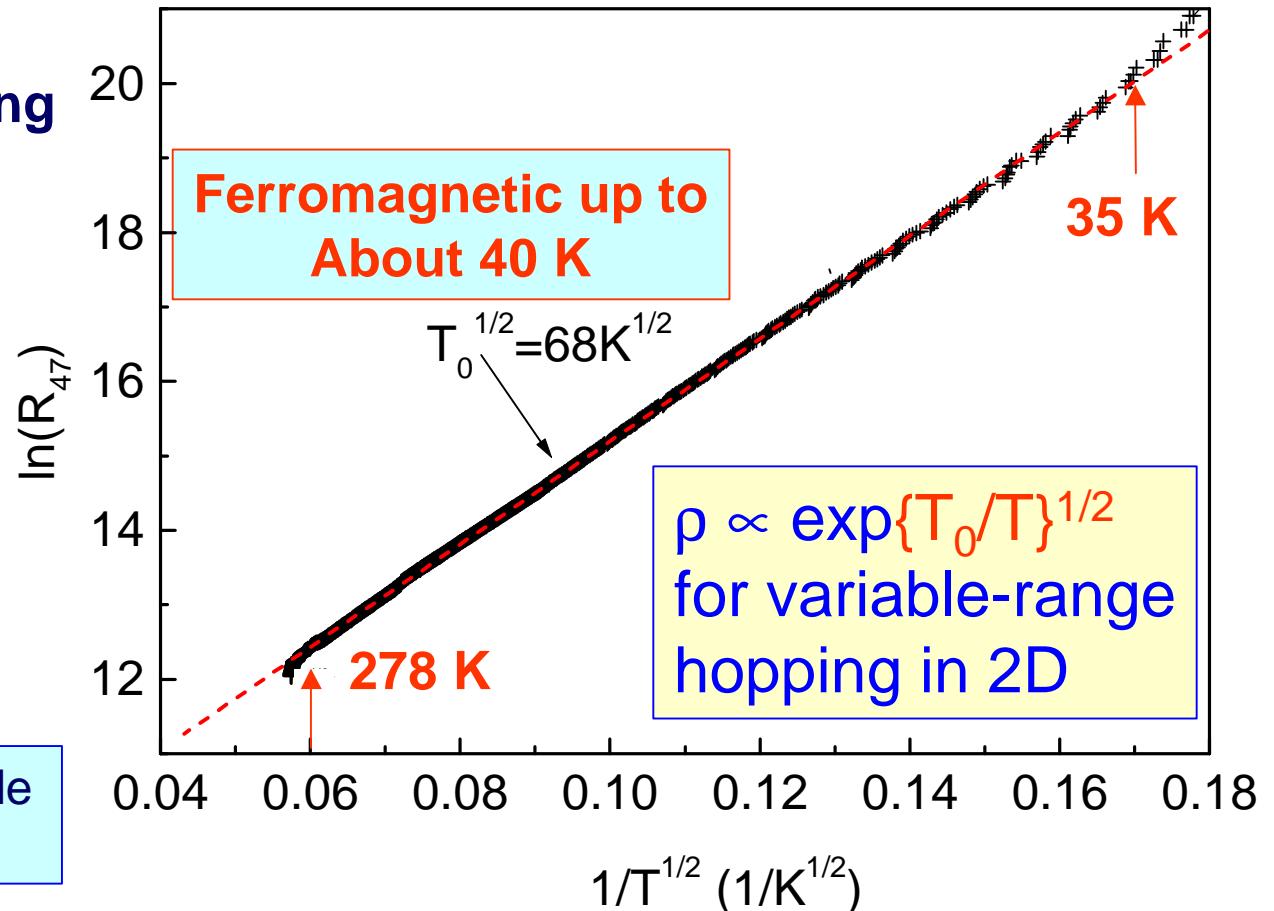
- Periods of digital alloys from Bragg peaks agree well with thickness measured *in situ*
- Good structural quality

GaMnAs DIGITAL ALLOY (16 ML GaAs/0.5 ML Mn)

Samples are all insulating
(resistance vs.
temperature)



Behavior observed over wide
temperature range



B.I. Shklovskii and A.L. Efros, *Electronic Properties of Doped Semicond.*, ed. M. Cardona, (1984).

GaAs/Mn DIGITAL ALLOYS



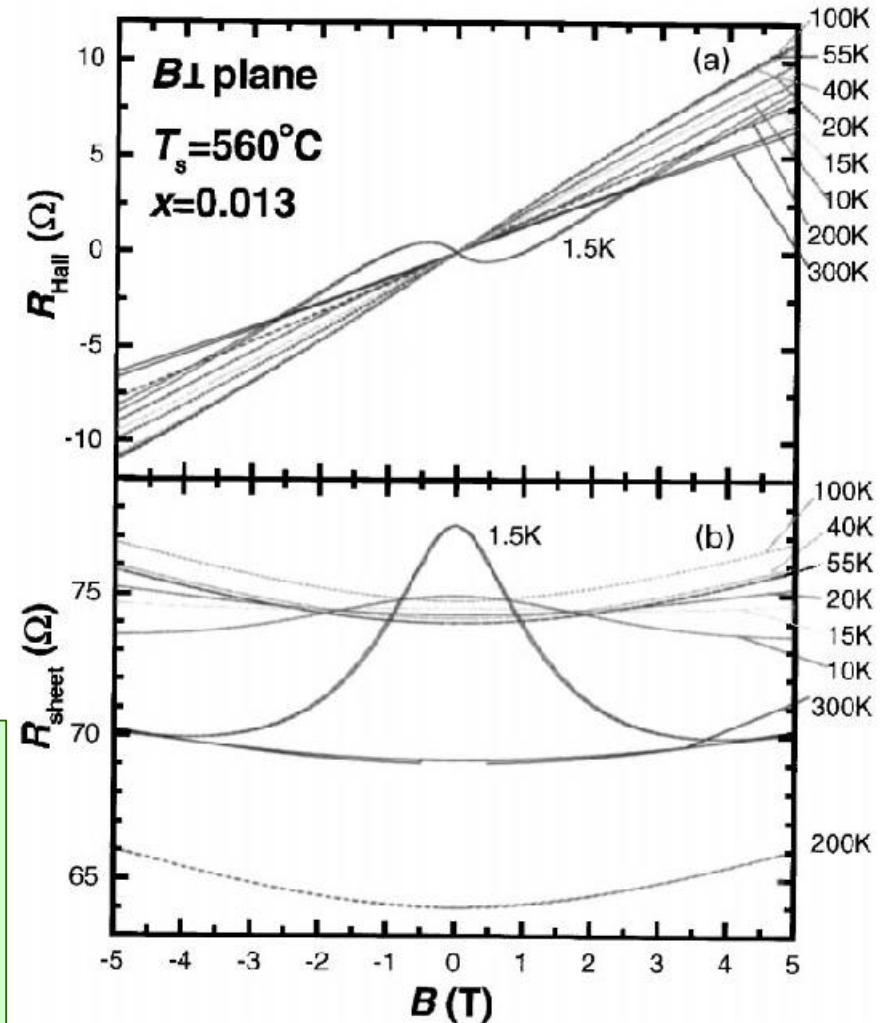
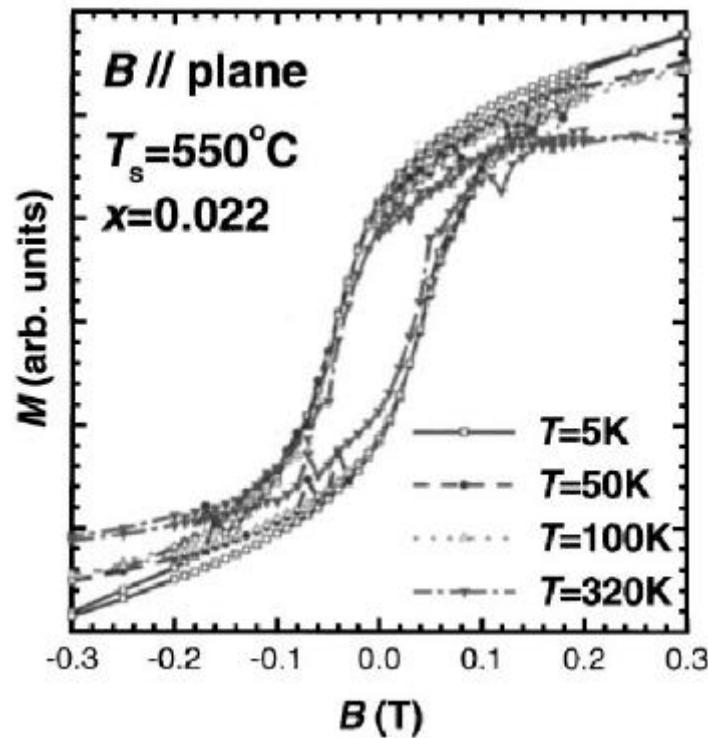
Current Status

- High resistivity
- Weak interlayer coupling
- Low T_c (~50 K)

Future Work

- Optimize growth conditions to obtain conducting samples
- Understand and improve carrier-mediated exchange interaction between Mn layers

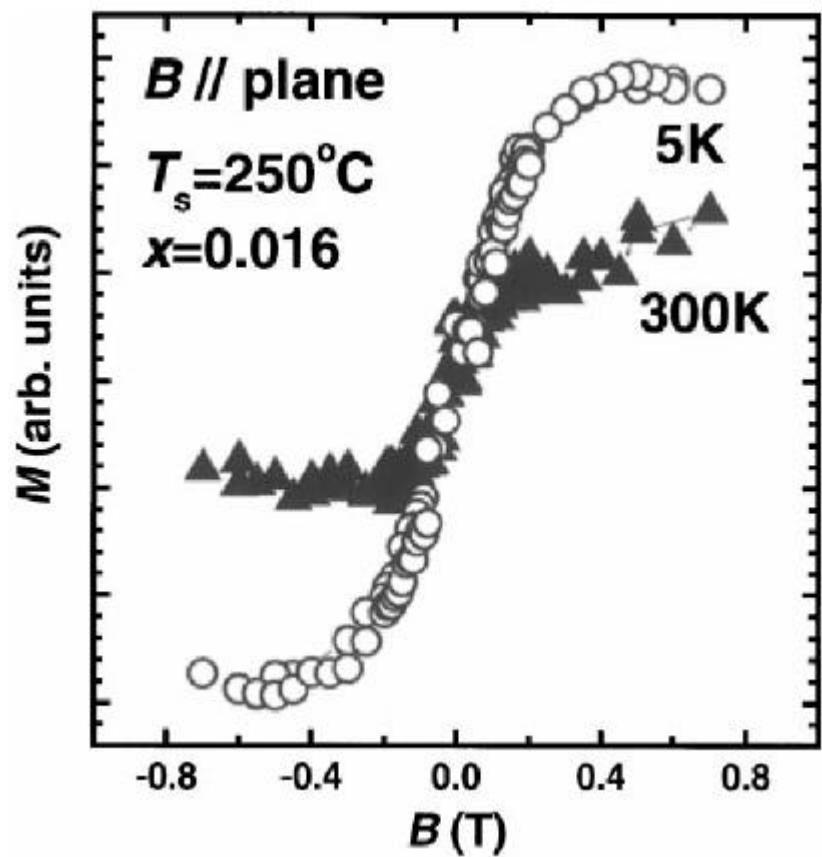
GaMnSb (HIGH TEMPERATURE GROWTH)



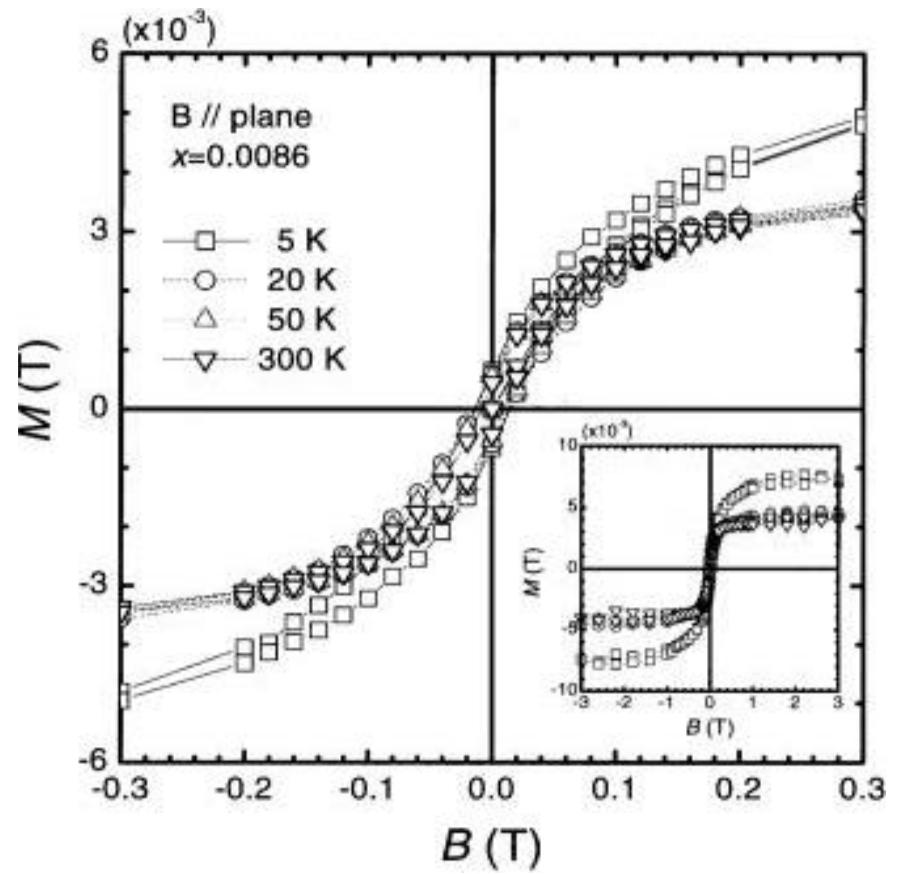
- Temperature independent and isotropic hysteresis loops → precipitates
- Carriers do not interact with precipitates, in the absence of Schottky barriers between MnSb and GaSb

E. Abe, et al., Physica E 7, 981 (2000)

GaMnSb (LOW TEMPERATURE GROWTH)

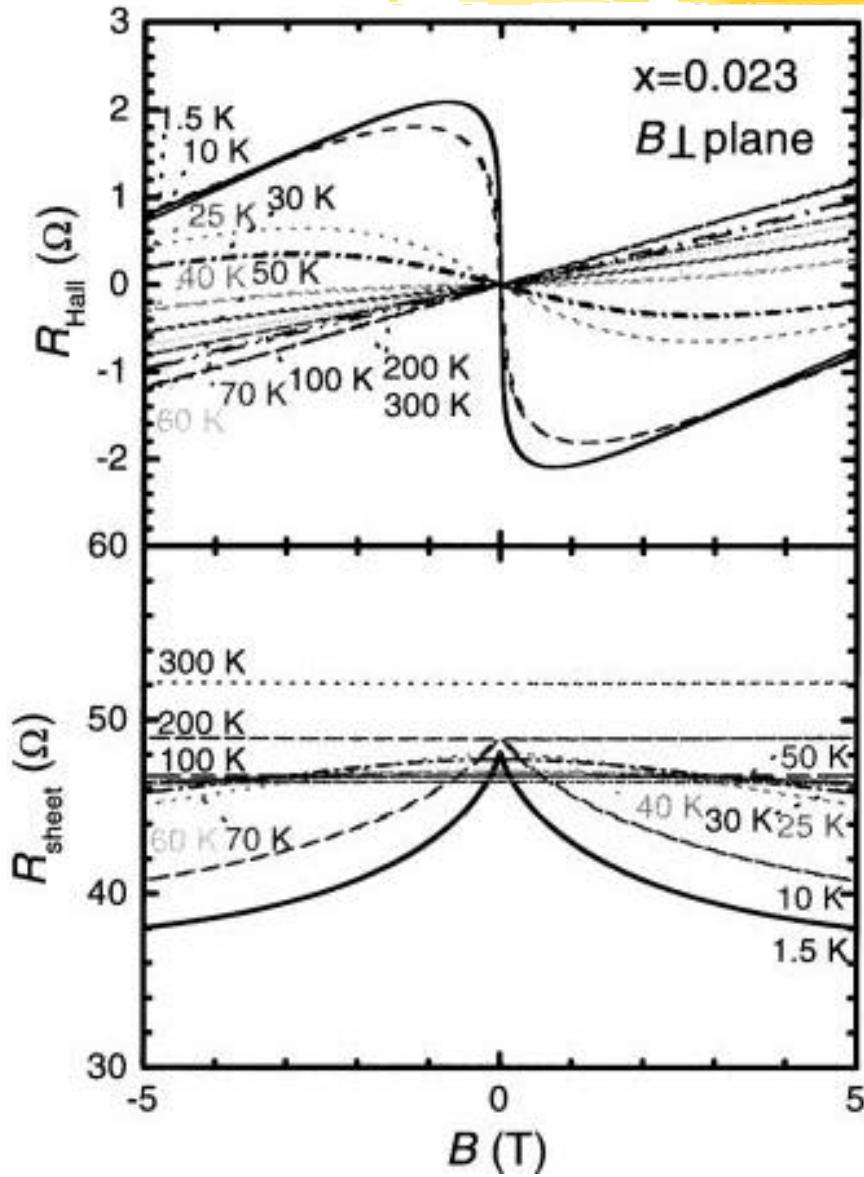


E. Abe, et al., Physica E 7, 981 (2000)



F. Matsukura, et al., JAP 87, 6442 (2000)

LT GaMnSb



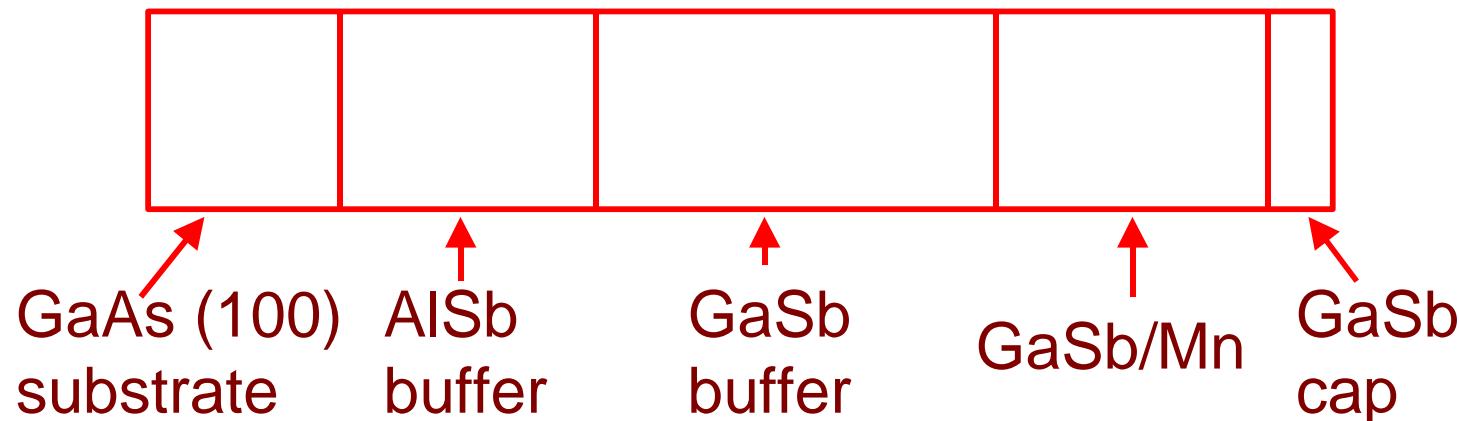
- Clear anomalous Hall effect observed (with negative anomalous Hall coefficient)
- Two phases
 - Ferromagnetic MnSb clusters
 - Ferromagnetic GaMnSb
- No interaction between ferromagnetic clusters and holes
- $T_C \sim 25$ K

F. Matsukura, et al., JAP 87, 6442 (2000)

GaSb/Mn DIGITAL ALLOYS

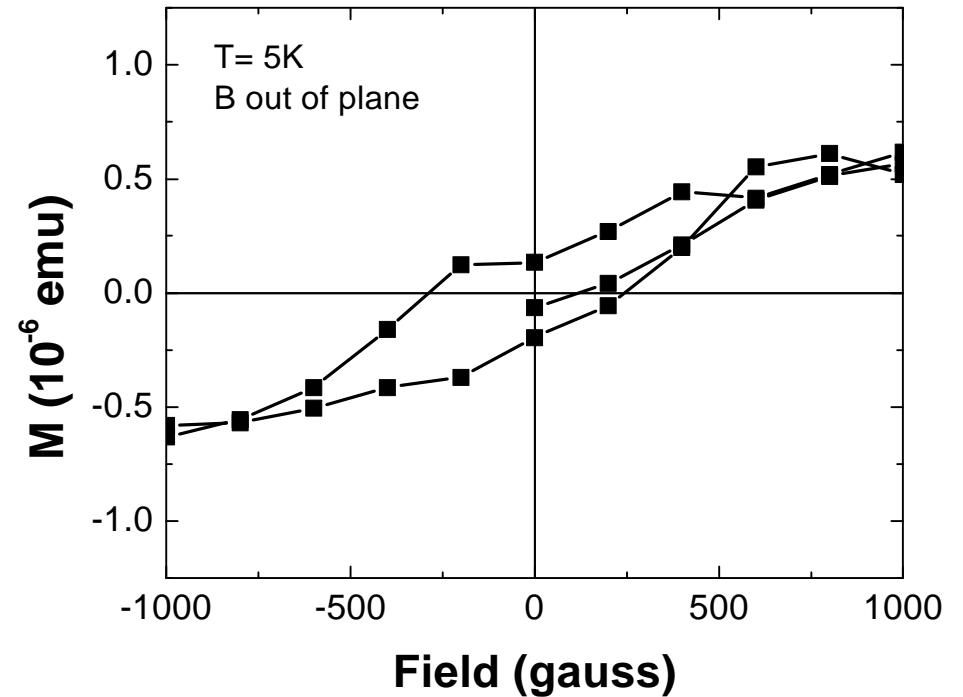
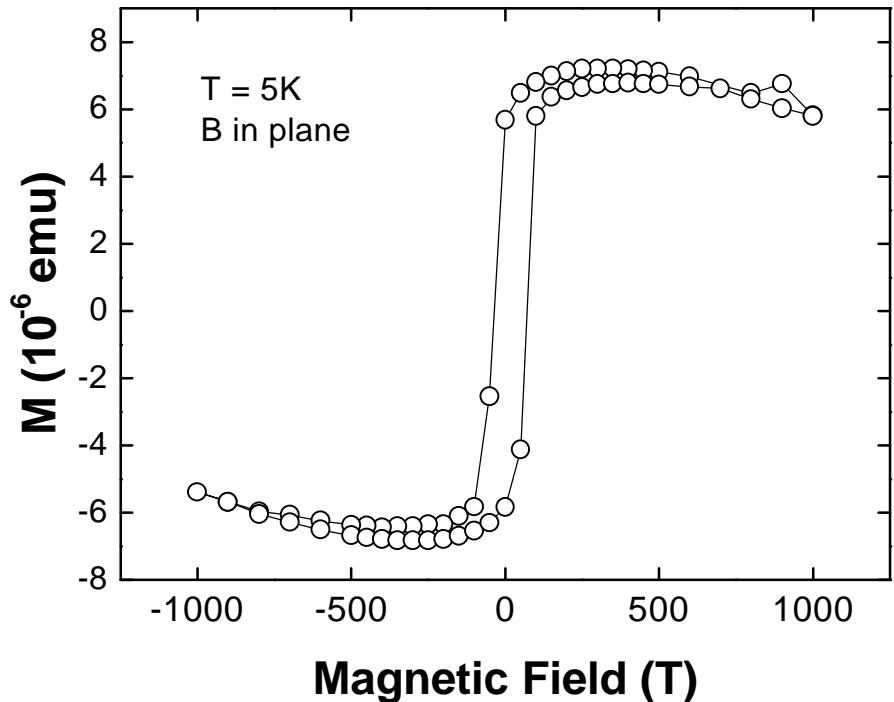
Higher valence band ➔ higher doping efficiency

Structure:



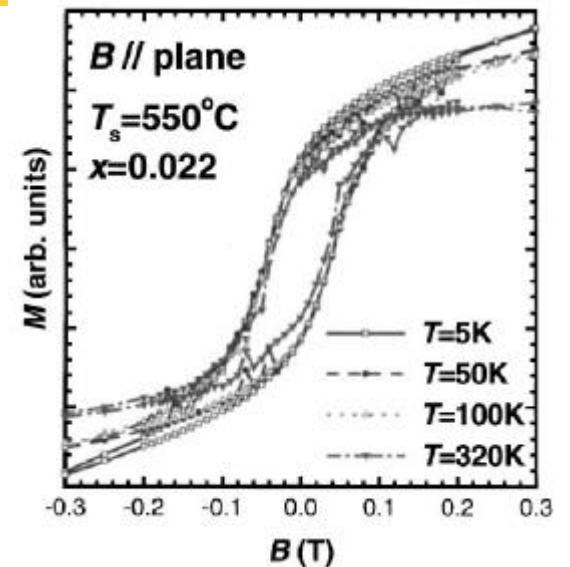
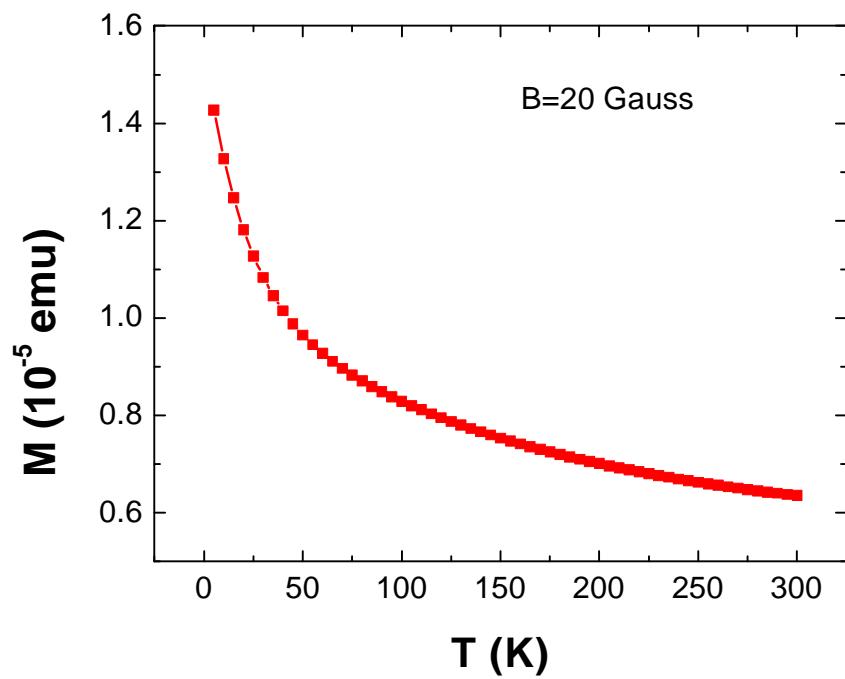
- Variation of Mn layer spacing
- Variation of Mn layer coverage
- GaSb/Mn growth temperature: 250°C

MAGNETIC ANISOTROPY

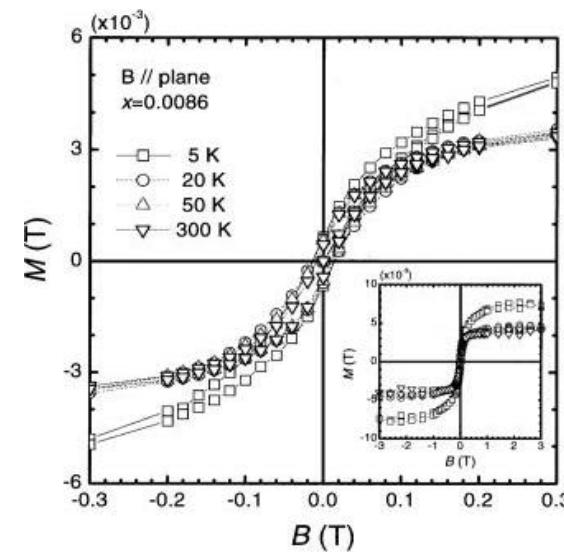


Anisotropic hysteresis loops (in-plane easy axis)

HYSTERESIS AND T_c

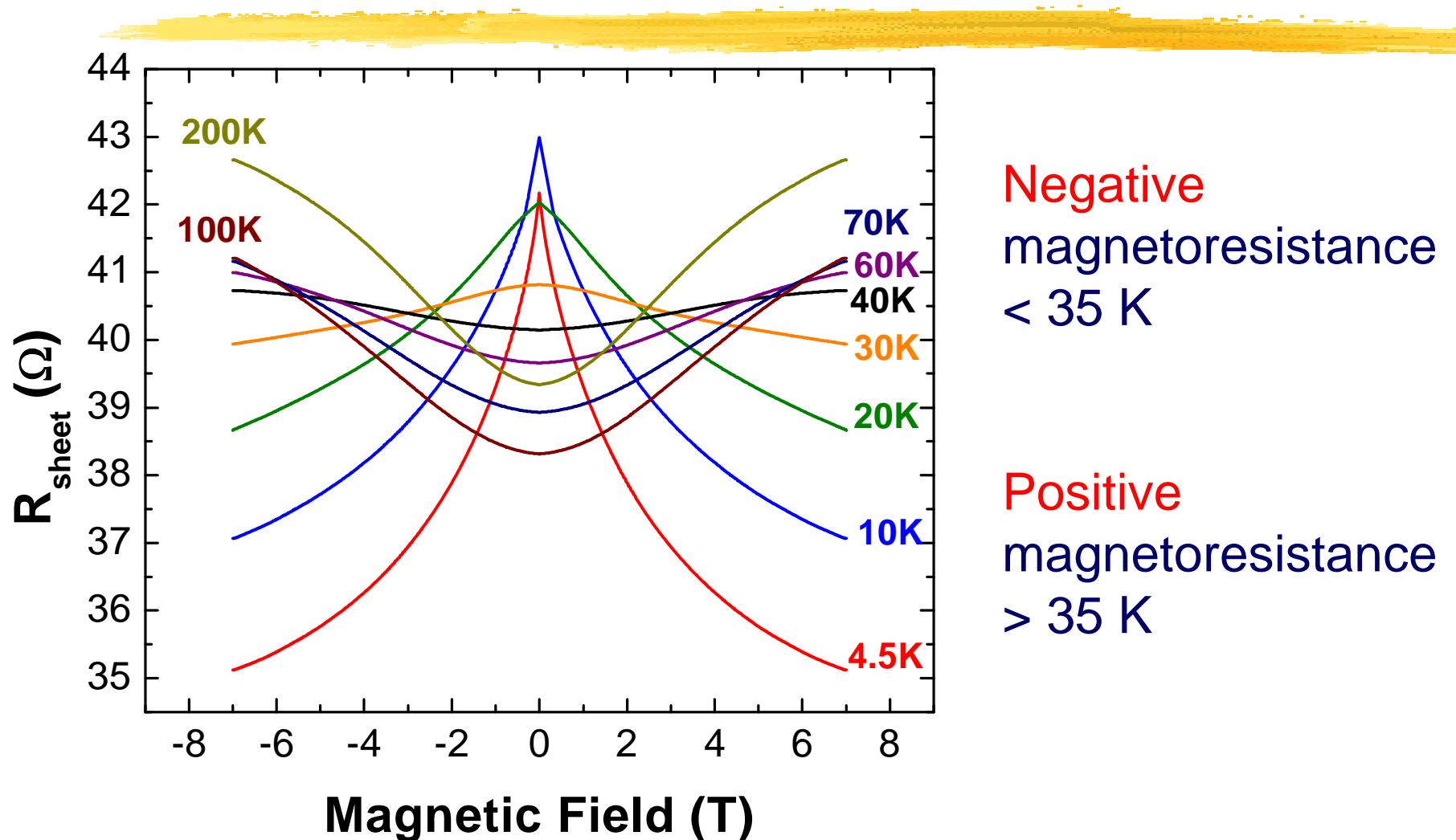


High T_{sub}



Low T_{sub}

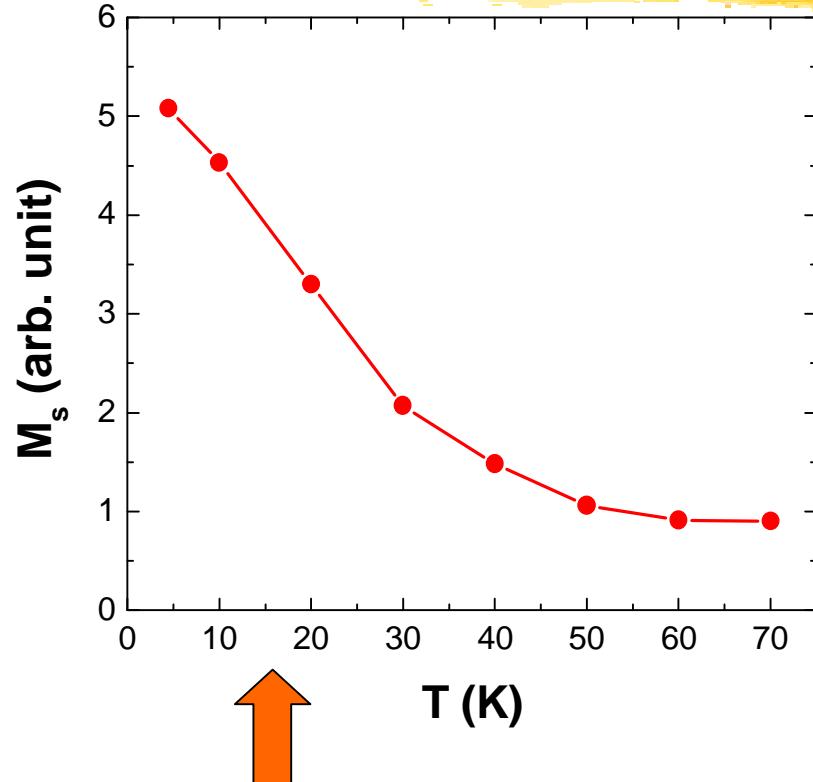
MAGNETORESISTANCE



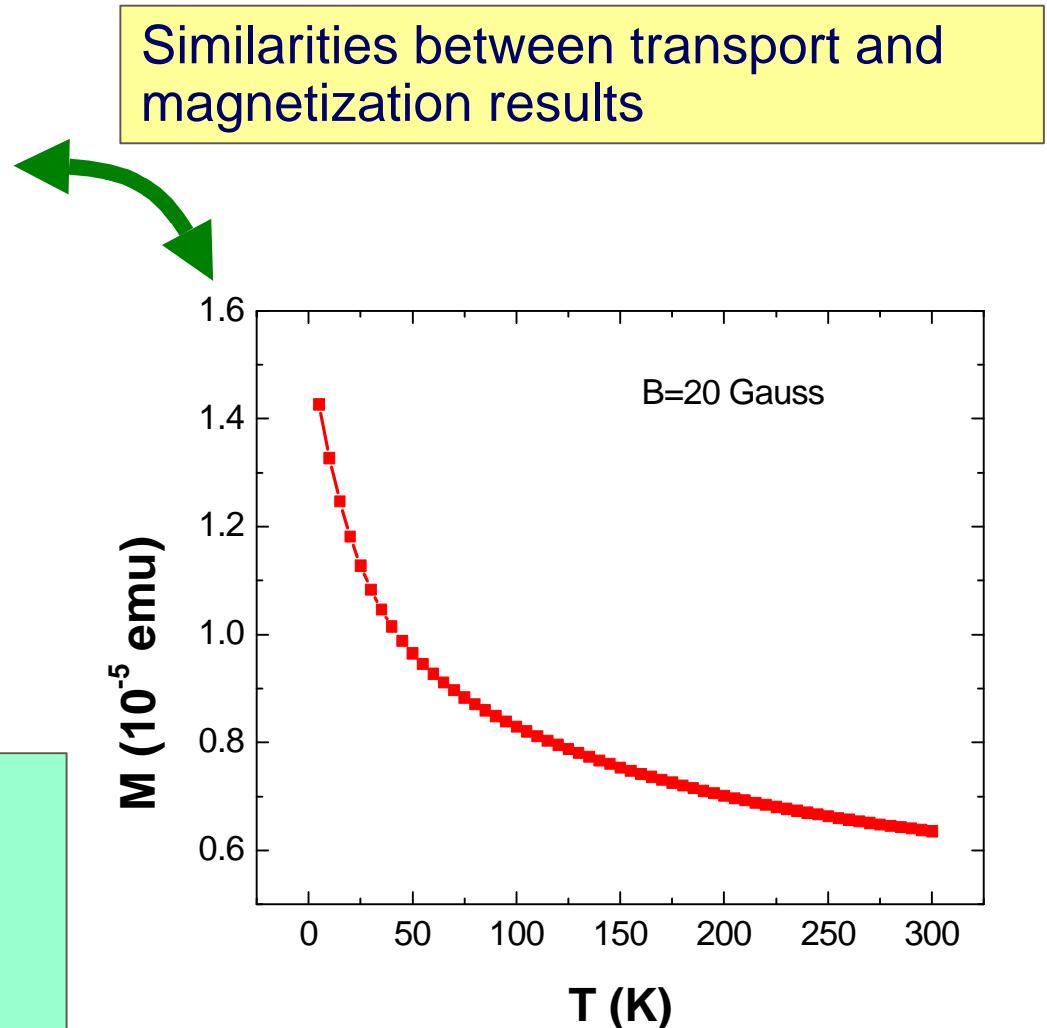
Negative
magnetoresistance
 $< 35 \text{ K}$

Positive
magnetoresistance
 $> 35 \text{ K}$

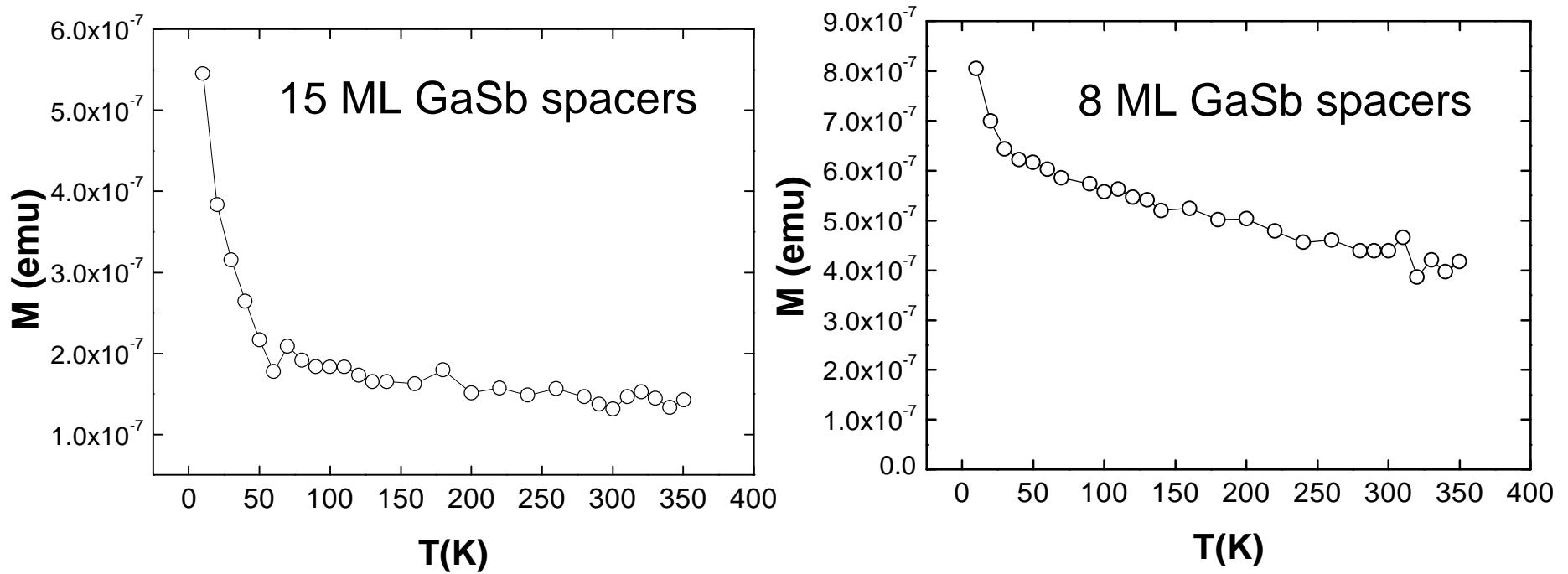
ARROT PLOT AND T_c



Saturation magnetization derived from the anomalous Hall effect
Magnetization as seen by holes (with one T_c around 50K)



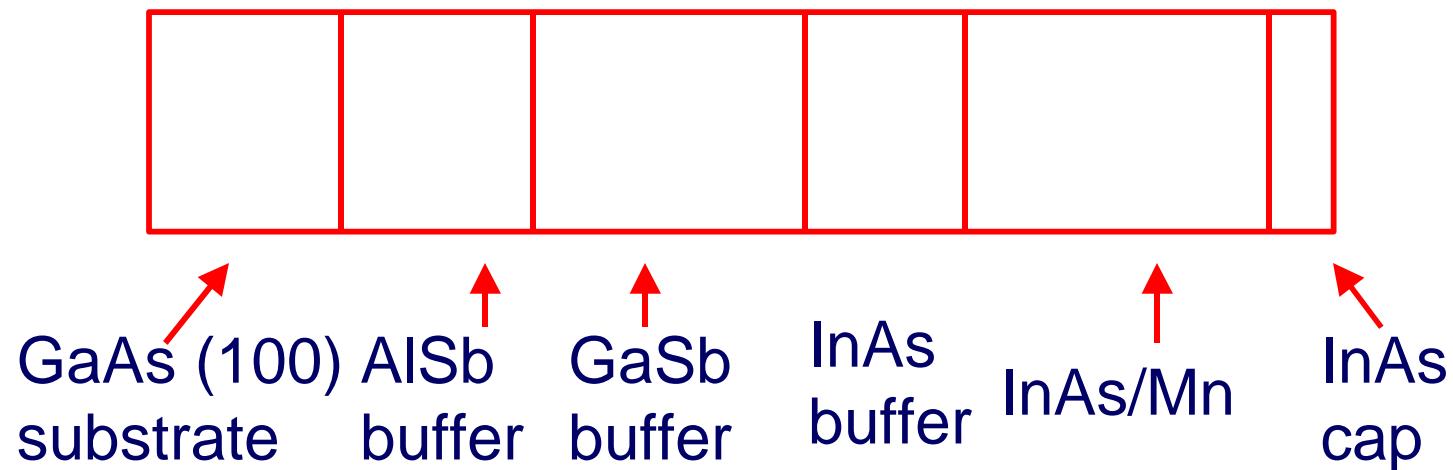
TEMPERATURE DEPENDENCE



Indication of two phases, one with T_C around 50 K and another with T_C above room temperature (precipitates)

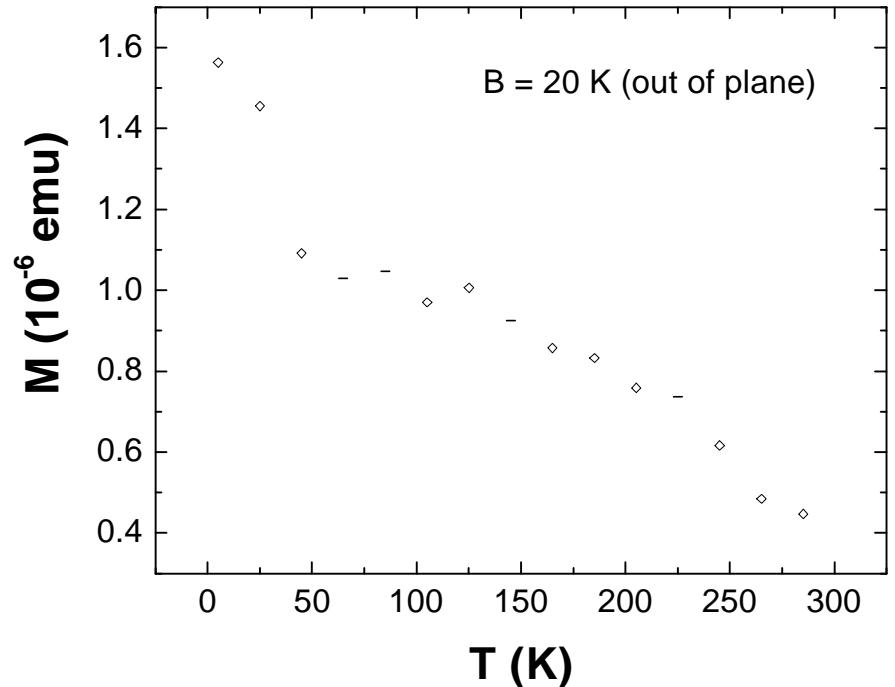
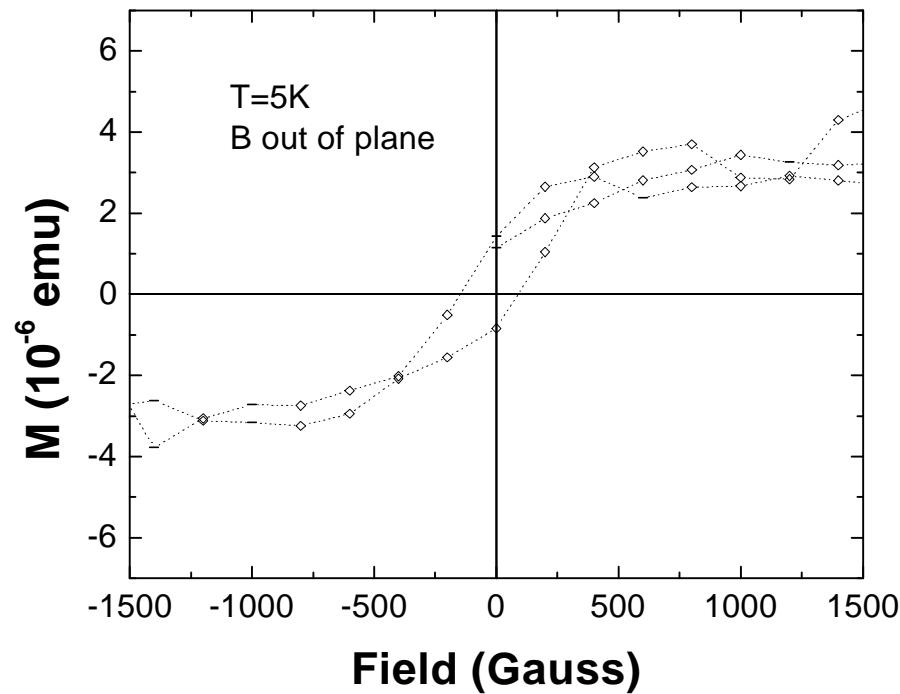
InAs/Mn Digital Alloys

- Structure:



- Variation of Mn layer spacing
- Variation of Mn layer coverage
- InAs/Mn growth temperature: 325°C

InAs/Mn DIGITAL ALLOYS



- Out-of-plane easy axis
- Presence of multiple phases in the system

SUMMARY



- Observation of hysteresis loops in GaSb/Mn digital alloys with T_c at least around 50 K (from both transport and SQUID measurements)
- MnSb clusters in GaSb/Mn with higher T_c
- Similar effects observed in InAs/Mn digital alloys